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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/687,768	10/20/2003	Yukio Narukawa	AZU.002	9596

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EXAMINER

TRINH, HOA B

ART UNIT	PAPER NUMBER
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2814

SHORTENED STATUTORY PERIOD OF RESPONSE	MAIL DATE	DELIVERY MODE
3 MONTHS	03/30/2007	PAPER

Please find below and/or attached an Office communication concerning this application or proceeding.

If NO period for reply is specified above, the maximum statutory period will apply and will expire 6 MONTHS from the mailing date of this communication.

Office Action Summary	Application No. 10/687,768	Applicant(s) NARUKAWA ET AL.	
	Examiner Vikki H. Trinh	Art Unit 2814	

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

- 1) ☒ Responsive to communication(s) filed on 24 January 2007.
- 2a) ☐ This action is **FINAL**. 2b) ☒ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

- 4) ☒ Claim(s) 1,2,4-10,12,13 and 19-21 is/are pending in the application.
- 4a) Of the above claim(s) _____ is/are withdrawn from consideration.
- 5) ☐ Claim(s) _____ is/are allowed.
- 6) ☒ Claim(s) 1,2,4-6,12,13 and 21 is/are rejected.
- 7) ☒ Claim(s) 7-10,19 and 20 is/are objected to.
- 8) ☐ Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

- 9) ☐ The specification is objected to by the Examiner.
- 10) ☐ The drawing(s) filed on _____ is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).
- 11) ☐ The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

Priority under 35 U.S.C. § 119

- 12) ☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
- a) ☐ All b) ☐ Some * c) ☐ None of:
1. ☐ Certified copies of the priority documents have been received.
2. ☐ Certified copies of the priority documents have been received in Application No. _____.
3. ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).
- * See the attached detailed Office action for a list of the certified copies not received.

Attachment(s)

- | | |
|------------------------------------------------------------------------------------------------------------------------|-----------------------------------------------------------------------------------------|
| 1) <input type="checkbox"/> Notice of References Cited (PTO-892) | 4) <input type="checkbox"/> Interview Summary (PTO-413)
Paper No(s)/Mail Date. _____ |
| 2) <input type="checkbox"/> Notice of Draftsperson's Patent Drawing Review (PTO-948) | 5) <input type="checkbox"/> Notice of Informal Patent Application (PTO-152) |
| 3) <input type="checkbox"/> Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)
Paper No(s)/Mail Date _____ | 6) <input type="checkbox"/> Other: _____ |

DETAILED ACTION

Continued Examination Under 37 CFR 1.114

1. A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on 1/24/2007 has been entered.
2. Claims 1-2, 4-10, 12-13, 19-21 are pending.

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless –

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

2. Claims 1, 5-6, 13, 21 are rejected under 35 U.S.C. 102(b) as being anticipated by Hosoba (5,814,839)

As to claim 1, Hosoba discloses a semiconductor light-emitting device (fig. 6), comprising a substrate 51 (fig. 6) and a n-type semiconductor layer 52 on the substrate 51, a recess (fig. 6), an active layer 53 (fig. 6) with a portion located within the recess and a portion located outside of the recess (fig. 6), and a p-type semiconductor layer 54 (fig. 6) stacked on a major surface of the substrate 51 (fig. 6) with a portion located within the recess and a portion located outside of the recess (fig. 6), wherein the portion of the p-type layer 54 has a planar

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bottom surface having the same planar orientation as the bottom surface of the recess and planar sidewalls having the same planar orientation as the sidewalls of the recess. Note that the term “planar” is to interpret as to mean “flat”.

As to claim 5, Hosoba discloses that at least one of surfaces of the n-type semiconductor layer 52 (fig. 6) contiguous to the active layer 53 (fig. 6) defines the major surface of the n-type semiconductor layer 52 (fig. 6).

As to claim 6, Hosoba discloses that at least one of surfaces of the n- type semiconductor layer 250 (fig. 4) contiguous to the active layer 310 (fig. 4) is a surface vertical to the major surface of the n- type semiconductor layer 250 (fig. 4).

As to claim 10, Hosoba shows that the active layer 53 (fig. 6) may inherently include a striped M or A plane , as viewed from an upper surface of the n- type semiconductor layer having a recess.

As to claim 13, Hosoba teaches that the active layer 53 (fig. 6) emits light components having two or more different major peak wavelengths in which the light components are mixed to show a color.

As to claim 21, Hosoba discloses that the recess is a triangle-shaped recess (fig. 6). Note a triangle is interpreted as a shape with 3 sides.

Claim Rejections - 35 USC § 103

3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

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4. The factual inquiries set forth in *Graham v. John Deere Co.*, 383 U.S. 1, 148 USPQ 459 (1966), that are applied for establishing a background for determining obviousness under 35 U.S.C. 103(a) are summarized as follows:

1. Determining the scope and contents of the prior art.
2. Ascertaining the differences between the prior art and the claims at issue.
3. Resolving the level of ordinary skill in the pertinent art.
4. Considering objective evidence present in the application indicating obviousness or nonobviousness.

5. This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

6. Claims 2, 4, 12 are rejected under 35 U.S.C. 103(a) as being unpatentable over Hosoba in view of Romano et al. (6,285,698; hereinafter 6,285,698).

Hosoba discloses the invention substantially as claimed, except that each of the semiconductor layers 52, 54 and the active layer 53 comprises a gallium nitride semiconductor layer

Romano discloses an analogous LED having an n-type semiconductor layer 250, an active layer 310, and a p-type layer 320; each of the layers comprises gallium nitride (col. 3, lines 45-55, col. 4, lines 60-65, col. 5, lines 30-55).

Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to modify the invention of Hosoba with the gallium nitride, as taught by Romano, so as to provide a wide range of wavelengths (col. 2, lines 5-10).

As to claim 4, Romano teaches that the active layer 310 (fig. 4) has a quantum well structure including a well layer comprising Indium and gallium nitride (col. 5, lines 30-35) so as to provide a wide bandgap necessary for short wavelength visible emission (col. 2, lines 15-20.)

As to claim 12, Romano discloses a first electrode 410 (fig. 4) is formed on at least a part of a surface of the n- type layer 230 (fig. 4), the surface being exposed, and a second electrode 420 (fig. 4) is formed on at least a part of the surface of the p- type layer 340 (fig. 4). Regarding to the rejection under 35 USC 103(a), how the surface is removed, either by etching or by other process, pertains to an intermediate step that does not affect the final structure of the device. See MPEP 2113. The patentability of a product does not depend on its method of production. If the product in the product-by-process claim is the same as or obvious from a product of the prior art, the claim is unpatentable even though the prior product was made by a different process. *In re Thorpe*, 777 F. 2d 695, 698, 227 USPQ 964, 966 (Fed. Cir. 1985).

Double Patenting

7. The nonstatutory double patenting rejection is based on a judicially created doctrine grounded in public policy (a policy reflected in the statute) so as to prevent the unjustified or improper timewise extension of the "right to exclude" granted by a patent and to prevent possible harassment by multiple assignees. A nonstatutory obviousness-type double patenting rejection is appropriate where the conflicting claims are not identical, but at least one examined application claim is not patentably distinct from the reference claim(s) because the examined application claim is either anticipated by, or would have been obvious over, the reference claim(s). See, e.g., *In re Berg*, 140 F.3d 1428, 46 USPQ2d 1226 (Fed. Cir. 1998); *In re Goodman*, 11 F.3d 1046, 29 USPQ2d 2010 (Fed. Cir. 1993); *In re Longi*, 759 F.2d 887, 225 USPQ 645 (Fed. Cir. 1985); *In re Van Ornum*, 686 F.2d 937, 214 USPQ 761 (CCPA 1982); *In re*

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Vogel, 422 F.2d 438, 164 USPQ 619 (CCPA 1970); and *In re Thorington*, 418 F.2d 528, 163 USPQ 644 (CCPA 1969).

A timely filed terminal disclaimer in compliance with 37 CFR 1.321(c) or 1.321(d) may be used to overcome an actual or provisional rejection based on a nonstatutory double patenting ground provided the conflicting application or patent either is shown to be commonly owned with this application, or claims an invention made as a result of activities undertaken within the scope of a joint research agreement.

Effective January 1, 1994, a registered attorney or agent of record may sign a terminal disclaimer. A terminal disclaimer signed by the assignee must fully comply with 37 CFR 3.73(b).

8. Claims 1-2, 4-10, 12-13, 19-21 rejected on the ground of nonstatutory obviousness-type double patenting as being unpatentable over claims 2-19 of U.S. Patent No. 6,876,009. Although the conflicting claims are not identical, they are not patentably distinct from each other because patent '009 discloses a LED having a n-type semiconductor layer, a recess, a p-type semiconductor layer, wherein the layers include gallium nitride, which is essentially the similar to the claims of the present application.

Allowable Subject Matter

9. Claims 7-10, 19-20 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

10. The following is a statement of reasons for the indication of allowable subject matter: The prior art of record does not disclose or fairly suggest either in singly or in combination a light emitting device comprising an active layer having M or A planes that make a specific angle of 30, 60, 90, 120, 150, 210, 240, 270, 300, or 330 degrees, a major surface of the n-type semiconductor layer is a C-plane of the gallium nitride layer; and other elements in the claims.

Response to Arguments

11. Applicant's arguments filed 01/24/2007 have been fully considered but they are moot in view of the new rejection.

In the remarks, applicants argue that a planar bottom surface and planar sidewalls overcome the cited reference. The examiner disagrees. The term 'planar' is interpreted simply to mean "flat". The cited reference shows the bottom surface and sidewalls are flat, not curvy or round. Thus, the cited reference is still properly applied to the rejected claims.

The examiner notes that applicants fail to submit a response regarding to the double patenting rejection in the previous Office Action. It is advised that a complete response to all of the rejection in an Office Action is recommended so as to avoid any delay in the prosecution of this application.

Conclusion

Any inquiry concerning this communication or earlier communications from the Examiner should be directed to Vikki Trinh whose telephone number is (571) 272-1719. The Examiner can normally be reached from Monday-Friday, 9:00 AM - 5:30 PM Eastern Time. If attempts to reach the examiner by telephone are unsuccessful, the Examiner's supervisor, Mr. Wael Fahmy, can be reached at (571) 272-1705. The office fax number is 703-872-9306.

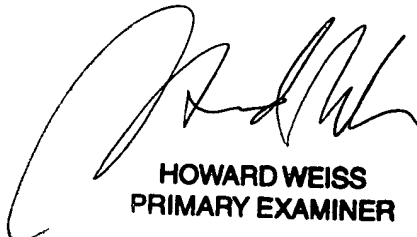
Any request for information regarding to the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Also, status information for published applications may be obtained from either Private PAIR or Public Pair. In addition, status information for unpublished applications is available through Private PAIR only. For

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more information about the PAIR system, see <http://pair-direct.uspto.gov>. If you have questions pertaining to the Private PAIR system, please contact the Electronic Business Center (EBC) at 866-217-9197 (toll free).

Lastly, paper copies of cited U.S. patents and U.S. patent application publications will cease to be mailed to applicants with Office actions as of June 2004. Paper copies of foreign patents and non-patent literature will continue to be included with office actions. These cited U.S. patents and patent application publications are available for download via the Office's PAIR. As an alternate source, all U.S. patents and patent application publications are available on the USPTO web site (www.uspto.gov), from the Office of Public Records and from commercial sources. Applicants are referred to the Electronic Business Center (EBC) at <http://www.uspto.gov/ebc/index.html> or 1-866-217-9197 for information on this policy. Requests to restart a period for response due to a missing U.S. patent or patent application publications will not be granted.

Vikki Trinh,
Patent Examiner
AU 2814



HOWARD WEISS
PRIMARY EXAMINER